REMARKS

Applicants request favorable consideration and allowance of the subject application in view of the preceding amendments and the following remarks.

Claims 1, 3-6, 13 and 14 are presented for consideration. Claim 1 is the sole independent claim. Claims 13 and 14 have been added to recite additional features of the subject invention. Support for these claims can be found in the application as originally filed. Therefore, no new mater has been added.

Claim 1 and 3-6 were previously allowed in this application. Applicants submit that these claims, as well as new claims 13 and 14, patentably define features of the near-field photomask and the near-field exposure apparatus of the present invention. Accordingly, the instant application should be in condition for allowance. Favorable consideration and an early Notice of Allowance are requested.

Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone at (202) 530-1010. All correspondence should continue to be directed to our below-listed address.

Respectfully submitted,

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